

AF

11w/2814



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the application of  
HORNING et al.

Serial Number:  
09/873,931

Filed: June 4, 2001

For:  
APPLICATIONS OF A  
STRAIN-COMPENSATED  
HEAVILY DOPED ETCH STOP  
FOR SILICON STRUCTURE  
FORMATION

Group Art Unit:  
2814

Examiner:  
Steven H. Rao

Docket No. H25542US

To the Commissioner of Patents and Trademarks:

Sir:

**AMENDMENT**

Please enter the following amendments in response to the Office Action mailed July 8, 2005.